

REMARKS

Entry of this supplemental amendment, reconsideration and withdrawal of all grounds of objection and rejection, and allowance of all the pending claims are respectfully requested in light of the following supplemental remarks.

Examiner Levitan is thanked for the courtesies extended in the telephonic interview conducted January 11, 2008.

In accordance with the discussion in the interview, and in the interest of expediting the prosecution of the application, Applicant has enclosed: (1) IEEE 802.3ah EFM TF, draft 1.0; and (2) a presentation to the IEEE on OAM Capability Discovery presented by Seyoun LIM and Soohyung KIM of Samsung. Applicant will file both documents as part of an IDS as well, and have enclosed these documents in an electronic filing of this supplemental amendment to enable the Examiner to receive same in an expedited manner.

Both of the enclosed documents were discussed during the interview, and the Applicant is providing the requested IEEE draft document. The proposal on OAM Capability Discovery has been provided to show that the subject matter was presented to the IEEE as a proposal, and was not part of the standard.

Therefore in view of the amendment entered via RCE and this supplemental amendment, Applicant respectfully requests reconsideration and withdrawal of all grounds of objection and rejection, and allowance of the pending claims.

Should the Examiner deem that there are any issues which may be best resolved by telephone, please contact Applicant's undersigned representative at the number listed below.

Respectfully submitted,
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Enclosures:
802.3ah EFM TF D1.0
OAM CAPABILITY DISCOVERY

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